Contents

Introduction 1

1 Fundamentals of Short and Ultrashort Pulse Laser Ablation 5
  1.1 Energy Absorption and Redistribution 5
  1.2 Material Removal Processes 9
  1.3 Material Vapor and Plasma 10
  1.4 Summary Description of the Ablation Process 11

2 Short and Ultrashort Pulse Laser Drilling 13
  2.1 Techniques for Drilling Process Investigation 13
    2.1.1 Post-Process Shape Survey 14
    2.1.2 On-line Depth Measurement 15
    2.1.3 Direct Observation Techniques 16
  2.2 Model Description of the Drilling Process 17
  2.3 Influence of the Processing Conditions on the Drilling Behavior 22
    2.3.1 Drilling under Reduced Ambient Pressure 22
    2.3.2 Drilling at High Repetition Rates 23
  2.4 Current State of Knowledge 25

3 In-situ Imaging of the Drilling Process 27
  3.1 Model System for Drilling in Opaque Materials 27
  3.2 In-situ Imaging System 30

4 Hole Shape Formation 33
  4.1 Hole Shape Evolution 33
    4.1.1 Phases of the Drilling Process 35
    4.1.2 Statistical Variations of the Drilling Process 37
  4.2 Influence of the Process Parameters 43
    4.2.1 Fluence and Pulse Energy 43
    4.2.2 Focus Position 47
    4.2.3 Wavelength 51
    4.2.4 Pulse Duration 57
  4.3 Three Phase Model of the Deep Drilling Process 64
## Contents

5 Hole Shape Formation Processes 67
   5.1 Influence of the Ambient Pressure .................................. 68
      5.1.1 Drilling Behavior under Different Ambient Pressure Conditions 69
      5.1.2 Hole Interior and Particle Debris Distribution .................. 74
   5.2 Interaction at High Repetition Rates .............................. 77
   5.3 Analysis of the Laser-generated Plasma ............................ 83
      5.3.1 Temporal Evolution of the Plasma Expansion .................. 84
      5.3.2 Depth-dependence of the Plasma Expansion .................... 86
   5.4 Light Propagation inside a Laser-drilled Hole ..................... 87
   5.5 Conclusion .......................................................... 94

Summary and Outlook 95

Appendix 99
   A Simulation of Ultrashort Pulse Absorption in Copper ............... 101
   B Simulation of Ultrashort Pulse Absorption in Silicon ............... 103
   C Comparison of BPM and FDTD Simulation ............................ 109

References 113

Publications in Peer-reviewed Journals 131

Conference Contributions 133